Supplementary information for

Graphene based flexible electrochromic devices

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Figure S1: **a,b**, Photographs of the bare nickel foil and graphene grown on nickel foil respectively. **c**, Photograph of graphene on PVC substrate.



Figure S2: *a-c*, Transfer line measurements for three different MLG. The slope yields the sheet resistance of the electrodes. The sheet resistance varies between 13 Ω /sq to 1300 Ω /sq. *d*, Optical transmission spectra of the MLG electrodes used for transfer line measurements.



Figure S3: Bending test for the graphene electrodes. **a**,**b** photographs of the MLG electrodes on flexible PVC substrates. **c**, Variation of resistance of MLG electrode as the electrode is deformed. **d**, the histogram of the resistance.



Figure S4: The variation of the optical transmittance of the device at +4 V. The intercalation process starts from the edge of the sample and propagates along the device.



Figure S5: Calculated optical transmission of MLG plotted against the number of layers. $T = (1-\alpha)^N$, where T is the transmission, α is the absorption of single layer which is around 2.3 % and N is the number of graphene layers.



Figure S6: *a,b*, Time trace of the percentage transmittance and charging current.